

What Is Claimed Is:

1 1. A system for equipment malfunction detection and
2 diagnosis, comprising:

3 equipment to transfer status information thereof at
4 preset intervals; and

5 a detection/diagnosis unit coupled to the equipment to
6 receive the status information, check whether the
7 status information conforms to a process control
8 standard, and if not, determine that the
9 equipment has a malfunction.

1 2. The system as in claim 1 further comprising a
2 status information database for storing the status
3 information of the equipment.

1 3. The system as in claim 1 wherein the
2 detection/diagnosis unit further generates a notification if
3 the equipment malfunctions.

1 4. The system as in claim 1 further comprising a
2 diagnostic database from which a recovery measure for the
3 malfunction is retrieved by the detection/diagnosis unit if
4 the equipment malfunctions.

1 5. The system as in claim 1 wherein the
2 detection/diagnosis unit further stops operation of the
3 equipment if the equipment malfunctions.

1 6. The system as in claim 1 wherein the status
2 information comprises a parameter value corresponding to at
3 least a process parameter.

1 7. The system as in claim 6 wherein the equipment is
2 semiconductor furnace equipment.

1 8. The system as in claim 7 wherein the process
2 parameter comprises a processed material identity, a wafer
3 count, a process program identity, a chamber identity, an
4 operator identity, a boat map, a step identity, a zone
5 temperature, a pressure, a mass flow controller, a gas flow,
6 a valve opening angle, or a leakage pressure.

1 9. A method for equipment malfunction detection and
2 diagnosis, comprising the steps of:
3 transferring status information of equipment at preset
4 intervals to a detection/diagnosis unit; and
5 checking whether the status information conforms to a
6 process control standard, and if not, determining
7 that the equipment has a malfunction.

1 10. The method as in claim 9 further comprising
2 storing the status information of the equipment.

1 11. The method as in claim 9 further comprising
2 generating a notification if the equipment malfunctions.

1 12. The method as in claim 9 further comprising
2 retrieving a recovery measure for the malfunction by the
3 detection/diagnosis unit if the equipment malfunctions.

1 13. The method as in claim 9 further comprising
2 stopping operation of the equipment if the equipment
3 malfunctions.

1 14. The method as in claim 9 wherein the status
2 information comprises a parameter value corresponding to at
3 least one process parameter.

1 15. The method as in claim 14 wherein the equipment is
2 semiconductor furnace equipment.

1 16. The method as in claim 15 wherein the process
2 parameter comprises a processed material identity, a wafer
3 count, a process program identity, a chamber identity, an
4 operator identity, a boat map, a step identity, a zone
5 temperature, a pressure, a mass flow controller, a gas flow,
6 a valve opening angle, or a leakage pressure.